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Modeling Electrical Switching of Nonvolatile Phase-Change Integrated Nanophotonic Structures with Graphene Heaters

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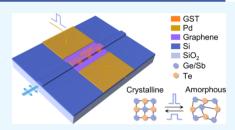
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ABSTRACT: Progress in integrated nanophotonics has enabled large-scale programmable photonic integrated circuits (PICs) for general-purpose electronic—photonic systems on a chip. Relying on the weak, volatile thermo-optic, or electro-optic effects, such systems usually exhibit limited reconfigurability along with high-energy consumption and large footprints. These challenges can be addressed by resorting to chalcogenide phase-change materials (PCMs) such as Ge₂Sb₂Te₅ (GST) that provide a substantial optical contrast in a self-holding fashion upon phase transitions. However, current PCM-based integrated photonic applications are limited to single devices or simple PICs because of the poor scalability of the optical or electrical self-heating



actuation approaches. Thermal-conduction heating via external electrical heaters, instead, allows large-scale integration and large-area switching, but fast and energy-efficient electrical control is yet to be achieved. Here, we model electrical switching of GST-cladintegrated nanophotonic structures with graphene heaters based on the programmable GST-on-silicon platform. Thanks to the ultralow heat capacity and high in-plane thermal conductivity of graphene, the proposed structures exhibit a high switching speed of \sim 80 MHz and a high energy efficiency of 19.2 aJ/nm³ (6.6 aJ/nm³) for crystallization (amorphization) while achieving complete phase transitions to ensure strong attenuation (\sim 6.46 dB/ μ m) and optical phase (\sim 0.28 π/μ m at 1550 nm) modulation. Compared with indium tin oxide and silicon p-i-n heaters, the structures with graphene heaters display two orders of magnitude higher figure of merits for heating and overall performance. Our work facilitates the analysis and understanding of the thermal-conduction heating-enabled phase transitions on PICs and supports the development of future large-scale PCM-based electronic-photonic systems.

KEYWORDS: phase-change materials, silicon photonics, graphene, nonvolatile, integrated nanophotonic structures, reconfigurable photonics

■ INTRODUCTION

The past few decades have witnessed the booming applications of photonic integrated circuits (PICs). Benefiting from their low-loss broadband transmission, PICs have demonstrated advantages over electronics in information transport including telecommunication and data center interconnects. Recently, thanks to remarkable advances in nanofabrication, the level of complexity of photonic integration has reached a new height, shedding light on future electronic-photonic systems on a chip.^{1,2} The availability of large-scale PICs, along with the slowing down of Moore's law3 and the von Neumann bottleneck in electronics, is thus offering PICs new opportunity to compete with electronic systems in energy-efficient broadband data processing and storage, in particular, for emerging applications such as neuromorphic computing, quantum information,^{2,5} and microwave photonics.^{6,7} Similar to electronic field-programmable gate arrays (FPGAs), success in these fields requires large-scale programmable PICs that have low-energy, compact, and high-speed building blocks with ultralow insertion loss. 8,9 Such general-purpose PICs can be reconfigured at will to meet the need for specific applications. Although numerous programmable photonic systems have been reported, 4-7,10 limited tunability of the systems is

exhibited because of the weak thermo-optic or electro-optic effects of the materials, leading to high energy consumption and large chip footprints. Microelectromechanical systems ¹¹ or resonator-based systems ^{12,13} can help improve the modulation strength, but they suffer from either a large actuation voltage of up to 40 V or a narrow optical bandwidth as well as high sensitivity to fabrication and temperature variations. ¹⁴ The volatile reconfigurability of these PICs also necessitates a continuous power supply rendering the systems energy-inefficient

To address these challenges, it is highly desirable to explore other active photonic materials with strong optical modulation and self-holding characteristics. Chalcogenide phase-change materials (PCMs) such as $Ge_2Sb_2Te_5$ (GST) are one such candidate. ^{15,16} First, PCMs can retain crystalline and amorphous states with a long retention time (for at least 10

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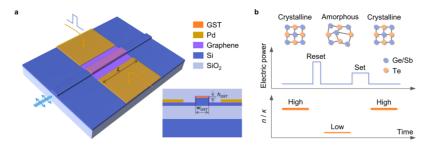


Figure 1. Device configuration. (a) Schematic of the proposed PINC with a graphene heater. Here, the silica cladding is hidden for clarity. The two ports of the PINC are connected with regular silicon rib waveguides in this case. Inset: cross-section of the hybrid cell. (b) Operation principle of electrical switching of the PINC with an external heater. The lattice structure, refractive index (n), and extinction coefficient (κ) of GST for amorphous and crystalline states and the electric power of the reset and set pulses are illustrated.

years)^{17,18} and extremely high contrast in resistivity¹⁷ and complex refractive indices (usually $\Delta n > 1$) over a wide spectral range, 15,16,19 thus enabling ultracompact, 20-25 broadband, 16,22,25 and multilevel 16,23,24,26-32 operations for nonvolatile integrated photonic applications without static energy consumption. Second, phase transitions of PCMs can be reversibly actuated by ultrashort (picosecond to nanosecond) optical or electrical pulses^{33–35} with high cyclability (potentially up to 10¹⁵ switching cycles)^{25,36} and low energy (down to femtojoules per bit or ~10 aJ/nm³). 16,37-39 Moreover, PCMs are highly scalable 40 and compatible with other substrates without the "lattice mismatch" issue as the as-deposited PCMs are usually in the amorphous state. Therefore, PCMs have been introduced to a variety of programmable PIC applications (usually placed on top of waveguides), including optical switches/modulators, ^{16,20-24,30,41-44} photonic memories, ^{26,29,31} and optical computing. ^{27,28,32,45,46} Recently, mixed-mode operations ^{39,47} and tunable volatility ⁴⁸ of PCMs have also been demonstrated. However, current PCM-based applications are limited to single devices or simple PICs. To scale up the PCM-integrated photonic devices to a much higher complexity as required for the future photonic FPGAs, it is important to have scalable control over the states of

In general, the phase transitions of PCMs on PICs can be triggered either by self-heating or thermal-conduction heating. Self-heating relies on the photothermal or Joule heating effect of PCMs to actuate the phase change process and can be realized by free-space optical switching, ^{16,20,41} on-chip optical switching, ^{26–32,38,39,43,46–49} or electrical threshold switching. ^{21,23,39,42} Resembling the approach used in rewritable optical disks, free-space optical switching, where PCMs are heated up by focusing laser pulses onto target devices in the far field, facilitates the switching of large-area PCMs at any position, but is not optimized for further integration and scaling because of the slow, diffraction-limited, inaccurate alignment process.¹⁶ In contrast, on-chip optical switching, mainly exploiting the evanescent coupling of near-field light pulses between waveguides and above PCMs, allows fully integrated all-optical operations of small-size PCMs down to the nanoscale.³⁹ However, it is challenging to switch large-area PCMs through this method because of the nonuniform heating, and the complexity of PICs is restricted because of the difficulty in light routing and cascaded-device heating.²⁸ Note that both the photothermal-based approaches will suffer from the low extinction coefficient of the amorphous state in the crystallization process, where multiple pulses or a singlestructured pulse are usually needed. The issue becomes

particularly severe when transparent PCMs are used. 50,51 Electrical threshold switching by contacting the two sides of PCMs in a circuit seems to be a better choice for large-scale integration. Nevertheless, it proves to be ineffective as the limited operation volume of PCMs because of the crystallization filamentation⁵² and nonuniform heating conflicts with the requirement of a relatively large size for photonic devices, resulting in low optical contrast between two states.³⁹ This method will also face challenges when it comes to lessconductive PCMs, which are generally also transparent because of their larger bandgaps. In comparison, thermal-conduction heating via external electrical heaters, 24,25,30,44 instead, can locally select and arbitrarily extend the switching region by increasing the size of the heaters. Therefore, this approach intrinsically eliminates all the above problems, enabling largearea phase-change photonic devices 22,25 with the potential of strong optical modulation and high-complexity integration. However, among the few works based on this approach, 24,25,30,44 no fast (>10 MHz) and energy-efficient $(\sim 10 \text{ aJ/nm}^3)$ electrical control has been reported so far. To maximize the advantages of thermal-conduction heating in terms of both optical and heating performance, the optical waveguide and heating system of phase-change integrated nanophotonic cells (PINCs), that is the fundamental unit of PCM-integrated photonic devices, remain to be improved and the heating process requires to be analyzed and optimized. To assist the development of the future large-scale PCM-based PICs, it is also important to develop a comprehensive model that has the capability of controlling and predicting the device performance.

In this work, we propose and model electrical switching of nonvolatile PINCs with graphene heaters based on the programmable GST-on-silicon platform. 16,22,25 Thanks to the ultra-low heat capacity and high in-plane thermal conductivity of graphene, 53,54 the proposed structures exhibit a high switching speed of ~80 MHz and a high energy efficiency of 19.2 aJ/nm³ (6.6 aJ/nm³) for crystallization (amorphization) while achieving complete phase transitions to enable high optical contrast (\sim 6.46 dB/ μ m or \sim 0.28 π/μ m at 1550 nm). Further analysis implies that gigahertz operations and energy efficiency near the fundamental limit³⁶ are possible for partial crystallization or amorphization that can be applied for multilevel operations. By comparing graphene with indium tin oxide (ITO) and silicon p-i-n diode heaters, we conclude that the PINCs with graphene heaters have the best heating and overall performance with 2 orders of magnitude higher figure of merits. By tuning the Fermi level $(E_{\rm F})$ of graphene to

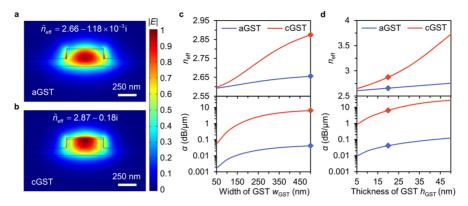


Figure 2. Dependence of optical performance on the waveguide geometry. (a,b) Normalized electrical field profile and the complex effective index ($n_{\rm eff}$) of the fundamental quasi-transversal electric mode of the GST-on-silicon hybrid waveguide with (a) aGST and (b) cGST at a wavelength (λ) of 1550 nm. The width and thickness of the GST are 500 and 20 nm, respectively. (c,d) Effective refractive index ($n_{\rm eff}$) and the attenuation coefficient ($\alpha = 4\pi\kappa_{\rm eff}/\lambda$, $\lambda = 1550$ nm) of the hybrid waveguide as a function of the (c) width and (d) thickness of the GST with $h_{\rm GST} = 20$ nm in (c) and $w_{\rm GST} = 500$ nm in (d). The marked dots correspond to the structure in (a,b) and denote the adopted waveguide geometry for the following analysis unless specifically pointed out. Here, the width and height of the silicon rib are fixed to be 500 and 120 nm, respectively. Neither heaters nor metal contacts are involved at this stage.

the Pauli blocking region, 55-58 even better optical performance and lower operation voltage can be achieved.

■ RESULTS AND DISCUSSION

Device Configuration and Modeling. As illustrated in Figure 1a, the proposed PINC is composed of a GST-onsilicon hybrid waveguide (where a thin film of GST with a width of w_{GST} and a thickness of h_{GST} is placed on top of the silicon rib waveguide) with a certain length (L) based on a silicon-on-insulator (SOI) wafer with a 220 nm-thick silicon layer on top of a 3 μ m-thick buried oxide. The geometry is similar to the one recently reported for optical switching. ¹⁶ To conduct the electrical switching, the PINC is conformally covered with monolayer graphene as the external heater with palladium contacts and a capping layer of SiO₂. Graphene, a single layer of carbon atoms arranged in a honeycomb lattice, has recently been introduced to integrated nanophotonic devices as a transparent heater 59-61 because of its high intrinsic in-plane thermal conductivity, ultra-low heat capacity, tunable transparency, and conductivity as well as good flexibility and compatibility with complementary metal—oxide—semiconductor (CMOS) processes. 53-58,62 Consequently, graphene is a promising candidate for external heaters in PINCs with great potential for high-speed and low-energy electrical switching. Rib waveguides are adopted here to reduce the step height for crackless transfer of graphene in practical applications. In order to evaluate the optical performance of the PINC, the input and output ports of the PINC are assumed to be connected with regular silicon waveguides, which is the case for most applications. Optical mode analysis is performed based on the frequency-domain finite-element method (FEM) using COMSOL Multiphysics (see Methods).

Differing from the self-heating approaches, electrical switching using external heaters relies on the transfer of electrical pulse-generated Joule heat from heaters to PCMs to actuate the phase transitions. For amorphization (Figure 1b, reset), a single pulse with high power is applied to the contacts to increase the temperature of PCMs above the melting point $(T_{\rm m})$ and then immediately removed to obtain rapid quenching, leaving PCMs in the disordered glass state with a low refractive index (n) and extinction coefficient (κ) . For crystallization (Figure 1b, set), PCMs are heated just above the

glass transition temperature (T_g) but below T_m by applying a pulse with a relatively low power for a long time to enable nucleation of small crystals and their subsequent growth, resulting in high optical constants in the crystalline state. To analyze the set and reset processes of the proposed PINC, we have established a fully coupled electro-thermal two-dimensional (2D) time-domain FEM model (see Methods) based on the cross-section of the PINC (Figure 1a, inset). Here, we assume that the phase transitions smoothly occur in a small temperature interval of $\Delta T_{\rm m} = 10~{\rm K}~(\Delta T_{\rm g} = 100~{\rm K})$ centered at $T_{\rm m} = 888~{\rm K}~(T_{\rm g} = 673~{\rm K})$ for the fast melting (the relatively slow crystallization). ^{52,63} Our model can be further improved by incorporating accurate kinetic description of the phase transitions, including melting, vitrification, nucleation, and growth. 2D simulations are more than sufficient to evaluate the heating performance given that the geometry of the PINC remains constant in the light propagation direction (assumed to be 1 μ m in this work) and the boundary-effect-induced nonuniform heating in the interface between the PINC and the regular waveguides can be alleviated by fully covering the PINC with a larger heater.44

Optical Performance. For large-scale programmable photonic applications, strong optical modulation and low insertion loss are essential for the optimal optical performance of the PINCs. Here, we define an optical figure of merit FOM₁ = $\Delta n_{\rm eff}/\kappa_{\rm effa}$, where $\Delta n_{\rm eff}$ denotes the effective refractive index (n_{eff}) change between the PINC with crystalline GST (cGST) and amorphous GST (aGST) that determines the modulation strength and $\kappa_{\rm effa}$ is the effective extinction coefficient ($\kappa_{\rm eff}$) of the PINC with aGST that reflects the insertion loss of the device as generally the loss for cGST is much larger than that for aGST. Both of the parameters are of great importance for optical phase modulation and the previously reported phasechange coupling modulation. ^{22,64} One can also define the optical figure of merit as $\Delta \kappa_{\rm eff}/\kappa_{\rm effa}$ for attenuation modulation (with $\Delta \kappa_{\text{eff}}$ being the effective extinction coefficient change). However, here we will primarily focus on FOM₁ since both of the figure of merits have a similar behavior (Figure S1). As the optical performance of the GST-on-silicon waveguides is a quite broadband near 1550 nm for at least 40 nm, 16 the following analysis is conducted at a single wavelength of λ = 1550 nm.

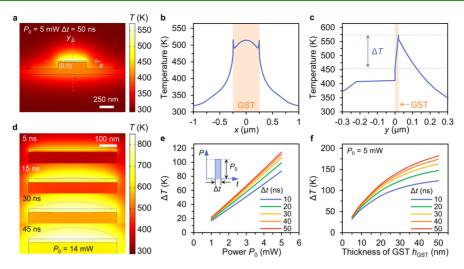


Figure 3. Temperature distribution analysis. (a) Temperature (T) profile of the PINC for aGST at the end of a pulse $(P_0 = 5 \text{ mW}, \Delta t = 50 \text{ ns})$. No phase transition is induced because of this pulse. The dashed lines denote the coordinate system with the x (y) axis parallel (perpendicular) to the surface of the GST film and the origin located at the center of the GST cross-section. (b) Temperature profile along the x axis in (a). (c) Temperature profile along the y axis in (a). The orange-shaded areas in (b,c) represent the position of the GST film. (d) Temperature distribution at different times for a crystallization (set) process $(P_0 = 14 \text{ mW})$. The red lines denote the contour of T = 723 K, within which the GST is assumed to be crystallized. (e) Temperature gradient $[\Delta T$, also marked in (c)] at the end of a pulse as a function of pulse power for different pulse widths. Inset: illustration of the applied pulse. (f) Temperature gradient at the end of a pulse as a function of aGST thickness for different pulse widths $(P_0 = 5 \text{ mW})$. The pulse energy is selected to be sufficiently low to avoid causing any phase transition of aGST in (e,f).

Improvement of FOM₁ can be achieved by optimizing the geometry of the GST-on-silicon hybrid waveguide. As FOM₁ does not strongly depend on the dimensions of the silicon rib (Figure S1a,b), only the influence of the size of the GST film is discussed here while the width and height of the silicon rib are fixed to be 500 and 120 nm, respectively. According to the mode analysis, strong modification of the mode profile and the complex effective index $(\tilde{n}_{\rm eff} = n_{\rm eff} - \kappa_{\rm eff} i)$ can be observed once the GST is electrically switched between the amorphous (Figure 2a) and crystalline (Figure 2b) states, indicating the substantial refractive and absorptive modulation effects. Figure 2c,d summarize the variation of the effective refractive index and attenuation coefficient ($\alpha = 4\pi\kappa_{\text{eff}}/\lambda$) of the hybrid waveguide with respect to the GST geometry for aGST and cGST. As expected, both the parameters and FOM₁ (Figure S1c,d) increase with the increase of the GST width and thickness. Therefore, in the following analysis, we select the width of the GST film to be as large as 500 nm (the same as the width of the silicon rib). However, the thickness of the GST film is set to be 20 nm by default unless otherwise specified considering the trade-off between FOM1 and the difficulty in switching (to be discussed later) as well as the signal-to-noise ratio in real experiments.

The optical performance can also be enhanced by reducing the additional loss from the metal contacts and heaters. Although placing the electrodes far away from the rib can theoretically avoid high insertion loss (Figure S2), it will compromise the energy efficiency since part of the generated heat will be dissipated around the long slab region. In this case, we choose the distance between the electrodes and the rib to be as close as 500 nm (the thickness of the metal is set to be 50 nm) while maintaining a moderate additional loss of \sim 0.01 dB/ μ m. The wet-transferred graphene grown by chemical vapor deposition usually has a Fermi level of around -0.28 to -0.23 eV. 65,66 Here, we assume the Fermi level of graphene to be -0.26 eV that leads to an additional loss of \sim 0.1 dB/ μ m (see Methods and Supporting Information Section 6). To

suppress the loss from graphene, one can electrically tune the Fermi level of graphene to the Pauli blocking region where interband transitions of electrons are prohibited (i.e. $E_{\rm F} < -0.4$ eV for a wavelength of 1550 nm) through a gate electrode. ^{55–58} This can potentially reduce the loss of graphene to ~0.002 dB/ μ m (see Methods and Supporting Information Section 6) while the increased energy consumption is significantly less than the switching energy (to be discussed later) and thus is negligible. As a result, our proposed PINC exhibits a FOM₁ of ~50 (~140 with gated graphene) and propagation loss per unit length of ~0.15 dB/ μ m (~0.05 dB/ μ m with gated graphene) with an attenuation modulation of ~6.46 dB/ μ m and an optical phase modulation of ~0.28 π/μ m at 1550 nm. The loss because of the mode mismatch between the regular silicon waveguide and the hybrid waveguide is ~0.03 dB on each side.

Heating Performance. In order to operate the electrical switching with high heating performance in terms of a high switching speed and energy efficiency, the real-time temperature (*T*) distribution of the PINC in response to an electrical pulse is calculated and analyzed based on the electro-thermal model. To successfully actuate the phase transitions without damaging the device, the raised temperature during the heating must be subjected to several constraints (the cooling rate during the quenching is also required to be about 1010 to 1011 K/s⁵² that is generally satisfied in our simulations). For crystallization, the temperature within the GST should be greater than $T_{\rm g}$ + $\Delta T_{\rm g}/2$ to ensure adequate nucleation and growth but less than $T_{
m m}$ - $\Delta T_{
m m}/2$ to prevent reamorphization. For amorphization, the temperature of the GST has to be elevated above $T_{\rm m} + \Delta T_{\rm m}/2$ but not so high to induce ablation. Besides, the temperature within the electrodes, heater, silicon waveguide, and silica cladding should always be kept below their melting points. In other words, the temperature gradient within the GST and the heat accumulating in other regions limit the implementation of the phase transitions.

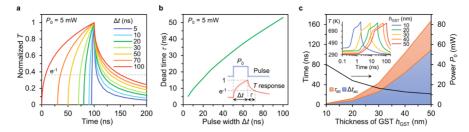


Figure 4. Transient response and speed analysis. (a) Normalized temperature response in the center of the GST cross-section to the pulses with different pulse widths. The power of the pulse is chosen to be as low as 5 mW in order to heat the cGST without inducing any phase transition. The dashed line denotes the position where the temperature is 1/e of the maximum. (b) Extracted dead time $(\tau, 1/e \text{ cooling time})$ from (a) as a function of pulse width. Inset: illustration of the applied pulse and temperature response. (c) Area chart of the minimum pulse width (Δt_{ac}) and the corresponding dead time (τ_{ac}) required to achieve complete crystallization actuated by the maximum allowed pulse power (black line) as a function of GST thickness. Inset: transient temperature response of the crystallization process for different thicknesses of GST.

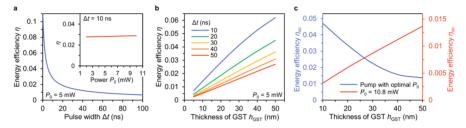


Figure 5. Energy efficiency analysis. (a) Energy efficiency (η) as a function of pulse width. Inset: pulse-power insensitive energy efficiency ($\Delta t = 10$ ns). (b) Energy efficiency as a function of GST thickness for different pulse widths. The pulse power is selected as low as 5 mW for (a,b) in order to heat the aGST without inducing any phase transition. (c) GST-thickness-dependent energy efficiency for crystallization (η_{ac}) actuated by a pulse with optimal power (blue line) and fixed power (red line).

Figure 3a presents a typical temperature profile (without phase transitions) of the PINC with aGST at the end of a pulse with an electrical power (P_0) of 5 mW and a pulse width (Δt) of 50 ns. In particular, the data cuts along the x axis (Figure 3b) and the y axis (Figure 3c) reveal that because of the flatness of the graphene, the GST is almost uniformly heated in the horizontal direction except the edges. However, the temperature of the GST in the vertical direction exhibits a large gradient with a much higher value close to the heater. Therefore, the temperature gradient within the GST (ΔT) can be represented by the absolute temperature difference between the top (T_{top}) and bottom (T_{bottom}) surface of the GST film along the y axis (i.e. $\Delta T = |T_{\text{top}} - T_{\text{bottom}}|$). With a moderate temperature gradient (Figure S3, ΔT remains ~100 K during the phase transition), the crystallization process (Figure 3d, P_0 = 14 mW) can proceed without re-amorphization. However, a very high-power pulse or a thick GST film will result in serious re-amorphization (Figure S4) because of the large temperature gradient within the GST. Further analysis (Figure 3e,f) confirms that the temperature gradient at the end of a heating pulse (without phase transitions) increases dramatically with the increase of the pulse power and the thickness of the GST film but increases less sensitively with the pulse width. Because small ΔT is desirable for a practical set (reset) process without any re-amorphization (ablation) and melting of other materials, a thin film of GST and a pulse with moderate power are preferred. In the following analysis, we will investigate the influence of pulse power, pulse width, and the thickness of the GST film on the switching speed and energy efficiency.

The switching speed of the PINC is limited by the pulse width and the dead time (τ , 1/e cooling time) because of the thermal relaxation. As the Set process usually requires a relatively longer pulse and thus determines the ultimate speed,

we mainly discuss the thermal relaxation of cGST and the crystallization period (t_{ac}) defined as the summation of the required pulse width $\Delta t_{
m ac}$ and the corresponding dead time $au_{
m ac}$ for crystallization). As presented in Figure 4a,b, the transient temperature response because of the heating and cooling of the cGST (without phase transitions) shows considerably higher cooling rates for shorter pulses. This could be intuitively understood that for longer pulses, more energy will get lost into the waveguide and substrate because of the thermal diffusion, 26,29 so that a larger heat capacity and a longer thermal time constant are expected leading to a longer dead time (and a lower energy efficiency as will be discussed later). In contrast, the dead time depends little on the pulse power (Figure S5a) and the thickness of the GST film (Figure S6a,b). This is, however, not the case for the crystallization. The minimum pulse width $(\Delta t_{\rm ac})$ required to achieve complete crystallization rapidly decreases with the increase of the pulse power (Figure S5b, with a fixed GST thickness) and linearly drops with the decrease of the GST thickness (Figure S6c, under fixed pulse power). As a result, the dead time (τ_{ac}) decreases a lot accordingly (because the pulse width is shorter). This is especially conspicuous if we consider the optimal (fastest) case (Figure 4c) that the maximum pulse power allowed to actuate crystallization without re-amorphization (limited by the temperature gradient as discussed earlier) is applied. The crystallization period substantially reduces with the increased power for the thinner GST film. Therefore, to obtain high-speed operations, a thin film of GST and a short pulse (enabled by using a high-power pulse) are needed. For the PINC with 20 nm-thick GST, the switching speed can be as fast as ~80 MHz (with $\Delta t_{\rm ac}$ = 8 ns and $\tau_{\rm ac}$ = 4.47 ns) that is 1 or more orders of magnitude larger than the previous results. 24,25,30,44 The speed is also 2 or more orders of magnitude larger than that of the traditional volatile, weak

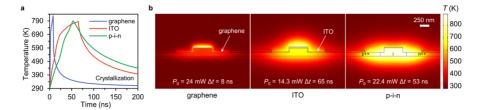


Figure 6. Comparison of the temperature response of the PINCs with different heaters. (a) Transient temperature response of the PINCs with different heaters for crystallization. (b) Temperature distribution at the end of a pulse during the crystallization process in (a) for the PINCs with graphene, ITO, and p-i-n heaters. The power and width of the Set pulse for three heaters are listed in the corresponding figures. p++(n++), heavily doped p (n)-type silicon region. i, intrinsic silicon region.

thermo-optic effect-based optical switches/modulators. ^{59–61} The latter is limited because of the requirement of the steady state and the tuning of large-volume materials achieved by a much longer pulse with a much slower cooling rate. It is worth noting that for partial crystallization, $\Delta t_{\rm ac}$ can be even less than 1 ns for 10 nm-thick GST (inset of Figure 4c), inferring that gigahertz operations are possible.

In order to achieve high energy efficiency, similar rules of thumb can be found. Here, the energy efficiency (η) is defined as the ratio of the absorbed heat energy in GST ($E_{\rm GST}$) at the end of a pulse and the applied electrical pulse energy ($E_{\rm pulse}$) and can be given by

$$\eta = \frac{E_{\text{GST}}}{E_{\text{pulse}}} = \frac{\int \rho C_p (T - T_0) dV}{P_0 \Delta t}$$
(1)

where ρ is the material density, C_p is the specific heat, T_0 is the initial ambient temperature (293 K), and the integral domain is over the entire GST film. As the set process usually consumes more energy, we primarily discuss the energy efficiency of heating the aGST and crystallization. Similar to the dead time, the energy efficiency of heating (without phase transitions) significantly diminishes with the increase of the pulse width (Figure 5a) but is insensitive to the change of the pulse power (inset of Figures 5a and S7). However, the energy efficiency is improved with the increase of the GST film (Figure 5b). This may mislead one to choose a thick GST film for low energy consumption. Indeed, if the crystallization is involved, a thin film GST requires a much shorter pulse to optimally actuate the phase transitions (using the maximum allowed power, Figure 4c) that ultimately results in higher energy efficiency for crystallization (η_{ac} , blue line in Figure 5c). In comparison, if a pump pulse with a fixed power is utilized, because the required pulse width does not increase much (Figure S6c), η_{ac} will still increase with the increase of the GST thickness (red line in Figure 5c). Consequently, a thin film of GST and a short pulse optimized by high power are critical to enable a high energy efficiency. In other words, a fast PINC is also an energyefficient device. For the PINC with 20 nm-thick GST, the consumed energy for crystallization can be optimized to be as low as ~0.192 nJ (19.2 aJ/nm³) with an energy efficiency of ~3.5% that is at least 1 order of magnitude more efficient than the previous results. 24,25,30,44 Based on a similar trend, the consumed energy for amorphization can be as low as 0.066 nJ (6.6 aJ/nm³) that is almost 2 or more orders of magnitude more efficient than the previous results. 24,25,30,44 Note that the energy efficiency can be further improved if partial crystallization or amorphization is needed that is essential for multilevel operations. In this case, the pulse width can be much shorter (<1 ns as discussed earlier) so that it is possible to

reduce the energy consumption to near the fundamental limit (1.2 aJ/nm^3) . ³⁶

Comparison with ITO and p-i-n Heaters. From the above analysis, the proposed PINCs with graphene heaters exhibit excellent optical and heating performance. However, there exist two other candidates for transparent heaters. First, ITO is a common transparent conductor that has been widely used in optoelectronics and display technology. Moreover, silicon itself could act as a transparent heater as long as the cores of the waveguides are not heavily doped. In this case, to achieve enough conductivity while maintaining low loss, a pi-n junction could be adopted.²⁵ This type of heater is only valid for the silicon photonic platform in contrast to those nonvolatile silicon nitride photonic devices. Here, we compare the performance of PINCs with ITO, p-i-n, and graphene heaters through similar electrothermal models (see Methods). As illustrated in Figure S8, all three types of PINCs have the same rib waveguides and electrodes, but for the PINCs with ITO heaters, the rib waveguides are conformally covered with 20 nm-thick ITO while for the PINCs with p-i-n heaters, the slabs are heavily doped by boron and phosphorus ion implantation (10²⁰ cm⁻³), 100 nm away from the left and right edge of the rib, respectively.

Because of the very different structures and material properties (Supporting Information Section 6), the PINCs with these heaters display extremely distinct transient temperature responses and temperature distributions for optimal crystallization (Figure 6) and amorphization (Figure S9) processes. As a result, their heating performance including the switching speed and energy efficiency is also very different. For instance, the PINCs with graphene heaters show the highest switching speed thanks to the ultra-low heat capacity and high in-plane thermal conductivity of graphene, the PINCs with ITO heaters exhibit a very large temperature gradient near the GST because of the low thermal conductivity of ITO, and the PINCs with p-i-n heaters have severe thermal diffusion because of the high thermal conductivity of silicon. Note that despite directly contacting with silicon, graphene and ITO heaters limit the thermal dissipation to silicon because of the existence of the thermal boundary resistance (TBR) on the material interfaces as thermal barriers.⁶⁷ To quantitatively evaluate their heating performance, we define a heating figure of merit $FOM_2 = 1/E_{tot}/t_{ac}$ where E_{tot} indicates the total energy consumption for one cycle of switching that is the summation of the optimal electrical pulse energy for crystallization (E_{ac}) and amorphization (E_{ca}) and t_{ac} denotes the crystallization period that determines the switching speed. The overall figure of merit (FOM) for the PINCs can thus be described as the product of the optical and heating figure of merits (i.e. FOM = FOM₁ × FOM₂). Table 1 lists the essential

Table 1. Performance Comparison of the PINCs with Different Heaters

			crystallization			amorphization							
heater	$\Delta n_{ m eff}$	$\kappa_{ m effa}$	$\frac{\Delta t_{\rm ac}}{({\rm ns})}$	$ au_{\rm ac}~({ m ns})$	$P_0 \ (\mathrm{mW})$	E _{ac} (nJ)	$\frac{\Delta t_{\rm ca}}{({\rm ns})}$	$ au_{\mathrm{ca}} ag{ns}$	$\frac{P_0}{(\mathrm{mW})}$	E _{ca} (nJ)	FOM_1	$\begin{array}{c} FOM_2 \\ (nJ^{-1} \cdot ns^{-1}) \end{array}$	$FOM \atop (nJ^{-1} \cdot ns^{-1})$
graphene	0.22	4.38×10^{-3}	8	4.47	24	0.192	0.22	1.09	300	0.066	50 or 140 (gated)	0.31	16 or 43 (gated)
ITO	0.22	4.74×10^{-3}	65	58.84	14.3	0.93	2.4	24.66	250	0.6	46	0.0053	0.24
p-i-n	0.21	1.82×10^{-3}	53	108.19	22.4	1.187	20	56.02	58.8	1.176	117	0.0026	0.31

 $^a\Delta t_{\rm ac}$ ($\Delta t_{\rm ca}$): pulse width for crystallization (amorphization). $\tau_{\rm ac}$ ($\tau_{\rm ca}$): dead time for crystallization (amorphization). $E_{\rm ac}$ ($E_{\rm ca}$): optimal pulse energy for crystallization (amorphization).

performance and figure of merits for the PINCs with three types of heaters. According to Table 1, without tuning the Fermi level, the PINCs with graphene heaters can provide the best heating performance and overall performance with FOM₂ and FOM 2 orders of magnitude higher. Although the PINCs with p-i-n heaters have the best optical performance because of the low loss, they have the worst heating performance because of the severe heat dissipation. The overall performance for the PINCs with ITO and p-i-n heaters is close, but for ITO heaters, planarization is needed for practical applications and the large temperature gradient near the GST is concerning. In contrast, for p-i-n heaters the fabrication is relatively simple and CMOS-compatible and the temperature gradient is small because of the high thermal conductivity of silicon. In fact, such p-i-n heaters are already part of the silicon photonics foundry processes and thus can be readily adopted for PCMs photonics. The optical performance and the conductivity of the heaters for all the PINCs strongly rely on the carrier density of the heater materials. By electrical tuning the Fermi level to the Pauli blocking region, the additional loss from graphene is significantly suppressed so the PINCs with graphene will have the best optical performance. In the meanwhile, the conductivity of graphene is desirably increased, meaning that a lower operation voltage is needed (the present voltage for reset is \sim 20 V). For the PINCs with ITO and p-in heaters, because the increase of the carrier density will increase the extra loss, there exists a tradeoff to keep a moderate conductivity while maintaining low optical loss. Note that the high power listed in Table 1 is just used for the optimal heating performance. In practical applications, tens of milliwatts are enough to actuate the phase transitions.

CONCLUSIONS

In conclusion, we have modeled and analyzed electrical switching of nonvolatile GST-clad integrated nanophotonic cells with graphene heaters on the programmable GST-onsilicon platform. By leveraging the ultralow heat capacity and high in-plane thermal conductivity of graphene, a high switching speed of ~80 MHz and a high energy efficiency of 19.2 aJ/nm³ (6.6 aJ/nm³) for crystallization (amorphization) are optimally achieved (via a thin film of GST and a short pulse optimized by high power) for complete phase transitions ensuring strong attenuation (\sim 6.46 dB/ μ m) and optical phase (\sim 0.28 π/μ m at 1550 nm) modulation. Gigahertz operations and energy efficiency near the fundamental limit are possible for partial crystallization or amorphization during multilevel operations. Compared with ITO and silicon p-i-n heaters, the PINCs with graphene heaters have the best heating and overall performance with 2 orders of magnitude higher figure of merits. By gating graphene to the Pauli blocking region, even better optical performance and lower operation voltage can be expected. To further optimize the heating performance and conduct multilevel operations, a single structured pulse or pulse sequences can be considered. The optical performance for multilevel operations can then be determined by the degree of crystallization according to the electrothermal model.² With a high speed, high energy efficiency, and small footprints while maintaining good optical performance, our proposed PINCs with graphene heaters allow scalable control over the states of PCMs and thus promise the development of the future large-scale PCM-based programmable PICs. The comprehensive model built in this work also assists the analysis and understanding of the thermal-conduction heatingenabled switching processes on PICs and facilitate the design and optimization of the PINC-based devices such as nonvolatile phase-change optical switches/modulators, directional couplers, photonic memories, and optical neurons and synapses.

METHODS

Modeling of the PINCs with Graphene Heaters. The electrical switching of PINCs with graphene heaters is simulated by a fully coupled electro-thermal 2D time-domain FEM model using COMSOL Multiphysics. Specifically, an electrical model (electric currents, shell interface) based on the current continuity equation is utilized to predict the current and electric potential distribution in graphene. A thermal model (heat transfer in solids interface) based on the heat transfer equation $\rho C_p \frac{dT}{dt} = \nabla \cdot (k_{\rm th} \nabla T) + Q_e$ (where $k_{\rm th}$ is the thermal conductivity and Q_e is the heat source) is used to predict the temperature distribution in the whole device. The two models are cross-coupled via Joule heating and the temperature-dependent material properties (Supporting Information Section 6).

In the electrical model, the graphene is modeled as a thin electrically conductive shell (boundary) with a thickness of 0.335 nm. The metal contacts are connected to the two sides of the graphene shell and the applied pulses are assumed to have ideal shapes. Compared with the resistance of graphene, the contact resistances between the metal contacts and graphene are negligible 60 and thus are not included in the model.

In the thermal model, the infinite element domains are adopted for the left, right, and bottom boundary regions of the model while the convective heat flux boundary condition is used on the surface with a heat transfer coefficient of 5 W/(m²-K). Considering the relative thinness of GST and graphene and high operating temperature, TBR and surface-to-surface radiation boundaries are utilized. Besides, graphene is similarly modeled to a thin thermal conduction boundary based on the thermally thin approximation with a thickness of 0.335 nm. For simplicity without losing generality, the phase transition processes are phenomenologically modeled as that the material properties of GST are weighted sums of those in the amorphous and crystalline states in a small temperature interval of $\Delta T_{\rm m}=10~{\rm K}~(\Delta T_{\rm g}=100~{\rm K})$ centered at $T_{\rm m}=888~{\rm K}~(T_{\rm g}=673~{\rm K})$ of GST for melting (quenching and crystallization) with a latent heat of 66.81 kJ/kg (an exothermic heat of 37.22 kJ/kg) involved. S2,63 Note that $T_{\rm g}$ is set to

be higher than usual (\sim 423 K) because of the increased $T_{\rm g}$ at a high heating rate. ⁶³

The optical performance of the PINCs with graphene heaters is simulated using a frequency-domain 2D FEM wave optics model through the mode analysis (eigenvalue solver). The perfectly matched layer domains are adopted for the boundary regions of the model with the scattering boundary conditions applied to all the external boundaries. Graphene is modeled as surface current density boundaries that introduce Ohmic loss because of the optical-conductivity-induced surface current. 65

Modeling of the PINCs with ITO and p-i-n Heaters. Based on an identical model, the PINCs with ITO heaters are simulated except that instead of being treated as a thin film boundary, the ITO here is normally modeled as a 2D domain.

For the PINCs with p-i-n heaters, a semiconductor model (semiconductor interface) based on the Poisson's equation, current continuity equation, and drift-diffusion current density equations⁶⁸ is exploited to estimate the electric potential, current density, and carrier density distributions in the p-i-n junctions while the thermal model is identical to that for the PINCs with graphene heaters. In particular, the Fermi-Dirac carrier statistics and Jain-Roulston bandgap narrowing model are utilized because of the high doping level. The Arora mobility model is added to simulate the effect of phonon/lattice and impurity scattering while the Fletcher mobility model is used to describe the carrier-carrier scattering at a high voltage. Trap-assisted recombination and Auger recombination for a high bias are also considered in the model. The metal contacts are assumed to be ideal Ohmic and the applied pulses have ideal shapes. All the other external boundaries are electrically insulated. The carrier density distribution at semiconductor equilibrium is employed to determine the complex refractive index of the doped silicon (Supporting Information Section 6) for mode analysis.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/acsami.0c02333.

Optical performance; temperature distribution analysis; transient response and speed analysis; energy efficiency analysis; comparison of the PINCs with different heaters; and material parameters used in the model (PDF)

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Author Contributions

J.Z. and A.M. conceived the project. J.Z. performed the modeling of the devices. S.Z. and S.D. conducted the thermal conductivity modeling. P.X. helped with optical mode analysis. A.M. supervised the overall progress of the project. J.Z. wrote the manuscript with input from all the authors.

Notes

The authors declare no competing financial interest.

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